

Size-Controlled Cu₂O Nanocubes by Pulse Electrodeposition

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Abstract : In this work, highly uniform size-controlled Cu₂O nanocubes can be successfully formed by means of pulse electrodeposition. The size distribution, crystal structure, and chemical state of deposited Cu₂O nanocubes are characterized using scanning electron microscopy, transmission electron microscopy, X-ray diffraction and X-ray photoelectron spectroscopy. The phase transition from Cu₂O to Cu can be controlled by constant current electrodeposition as a function of deposition time. In particular, the size of the Cu₂O nanocubes can be controlled using pulse electrodeposition as a function of applied current density.

Keywords : Cu₂O Nanocube, Size control, Pulse electrodeposition, Phase transition

1. Introduction

Cuprous oxide (Cu₂O) crystal structure has advantages of no toxicity, low cost, availability, and high absorption coefficient at 2.17 eV (438 nm).^{1,2)} Such distinct properties make Cu₂O potential candidates for solar energy cell, catalysis, and gas sensors.³⁻⁵⁾ In addition, the Cu₂O phase is useful for negative electrodes in lithium ion batteries and for photochemical decomposition of water into O₂ and H₂ under visible light irradiation.⁶⁻⁸⁾

It has been well known that the shape and size-controlling of inorganic materials has great effects on their widely varying properties.⁹⁾ Many efforts have been intensively devoted to the synthesis of Cu₂O with a variety of shapes using electrochemical, thermal oxidation, solution-phase synthesis, sputtering, and chemical vapour deposition.¹⁰⁻¹⁷⁾ Among them, pulse electrodeposition method was found to be useful for nanostructure fabrication because of simple operation and uniform deposition.¹⁸⁻²⁰⁾ However, since it is stable in an extremely narrow range, the Cu₂O phase should be carefully fabricated.

Here, we report phase transition between Cu₂O and Cu and size-controlling of Cu₂O nanocubes using electrodeposition method. Using scanning electron microscopy (SEM), transmission electron microscopy (TEM), X-ray diffraction (XRD) and X-ray photo-

electron spectroscopy (XPS), size distribution, crystal structure, and chemical state of the electrodes were characterized.

2. Experimental

The Cu₂O and Cu on indium tin oxide (ITO) glass were electrodeposited in 5 mM copper sulfate (CuSO₄) aqueous solution. Electrodeposition was carried out under a constant mode or pulse mode, using a three-electrode cell with a Pt wire, an Ag/AgCl electrode and ITO glass as a counter, reference and working electrode, respectively. In case of an electrodeposition by constant current mode, -1 mA/cm² of direct current was applied for 10, 60, 300 and 600 s, respectively. In addition, Cu₂O nanocubes were prepared by pulse electrodeposition from -1 to -4 mA/cm² of pulse current with the 0.1 s on-time and 0.3 s off-time for 10 s at room temperature.

The morphology of deposited films was observed by means of SEM (JEOL JSM-6360A). The SEM investigation was carried out at room temperature at a voltage of 13 kV. TEM investigation was carried out using a Phillips-F20 Electron Microscope at an accelerating voltage of 200 kV and Cu grid was used as substrates. The crystal structures of the films were confirmed by XRD (Pohang Accelerator Laboratory, 5A HFMS). In order to analyze and compare the surface chemical states of the samples, XPS was carried out using a VG Scientific (ESCALAB250, Korea Basic Science

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Institute, Busan Branch) photoelectron spectrometer. The X-ray source was Al K_a with 1486.6 eV operating at 150 kV and 150 W. The base pressure of the system was 2×10^{-9} Torr.

3. Results and discussion

Fig. 1 shows SEM images of electrodes electrodeposited at -1 mA/cm^2 for 10, 60, 300, and 600 s. At the deposition time of 10 s, as shown in Fig. 1(a), the shape of the electrode is found to be cube. However, as shown in Fig. 1(b) and (c), as the deposition time increases, the density of cube in the electrodes is diminished and starts to agglomerate. Thus, as shown in Fig. 1(d), at the deposition time of 600 s, the cube in the electrode completely disappears with complete agglomeration. To identify crystal structures in the electrodes, as shown in Fig. 1(e), the XRD analysis

was carried out. At the deposition time of 10 s, as indicated in Fig. 1(e)-a, the XRD peaks at 36.4 and 42.2 are assigned to (111) and (200) planes of Cu₂O, respectively. Accordingly, the phase electrodeposited at -1 mA/cm^2 for 10 s is found to be Cu₂O cube. However, as shown in Fig. 1(e)-b and c, as the deposition time increases from 60, 300, to 600 s, in addition to the XRD pattern of Cu₂O, the diffraction peaks related to (111), (200) and (220) planes of Cu metal appear at 43.3, 50.4 and 74.1, respectively. This means that the peak intensity of Cu₂O is still stronger and the XRD peaks of Cu metallic phase start to appear. As already observed in the Fig. 1(b) and (c), the cube in the electrodes started to disappear and simultaneously agglomerate. Therefore, the agglomerates in the electrodes must be the most of Cu metallic phase including a slight amount of Cu₂O. In the XRD pattern of the electrode deposited for 600 s with complete agglomeration of the phase, as shown in Fig. 1(e)-d, the peak of Cu₂O still appears. However, that of Cu metallic phase becomes relatively stronger.

To confirm chemical transition between Cu⁺ and Cu⁰ of the Cu₂O and Cu, respectively, X-ray photoelectron spectra of the electrodes were obtained as shown in Fig. 2. The peak at 932.50 eV, which was corrected with reference to C1s (284.6 eV), corresponding to the binding energy of Cu2p, is in good agreement with data observed in Cu₂O.²¹ In addition, the peak at 932.70 eV and 933.60 eV corresponds to Cu and O²⁻-adsorbed Cu, respectively.²² In the spectrum of the electrode deposited for 10 s, there is only Cu₂O peak. However, as the deposition time increases from 10 to 600 s, the portion of Cu₂O is reduced while that of Cu is increased. The O1s core-level spectrum, peak at the lower energy of 530.3 eV, is in good agreement with O²⁻ in Cu₂O. The XPS peak at the higher energy of 531.7 eV, is attributed to O adsorbed on the surface. It can be seen that the portion of O²⁻ in Cu₂O reduces with increasing deposition time. This demonstrates that Cu₂O is continuously reduced to Cu metal. Thus, it is obvious that combining the XRD and XPS data, the electrodes deposited for 10 to 600 s shows phase transition between Cu₂O and Cu.

During electrodeposition process under any given condition, copper ions are continuously reduced. In other words, Cu₂O is formed and then perfectly reduced to Cu metallic phase as the following equations:

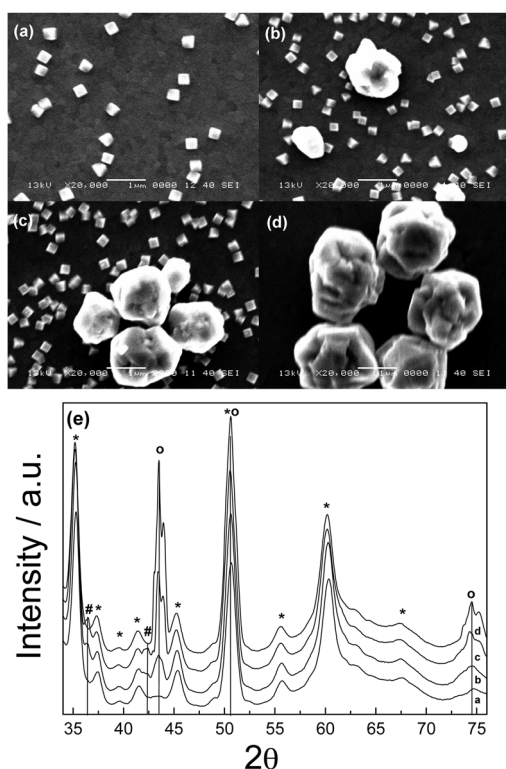


Fig. 1. SEM images of the electrodes electrodeposited for (a) 10, (b) 60, (c) 300 and (d) 600 s. (e) X-ray diffraction patterns of the electrodes electrodeposited for a.10, b.60, c.300 and d.600 s. The (*), (#) and (o) mark in the Fig. 1(e) represent XRD patterns of ITO glass, Cu₂O and Cu, respectively.

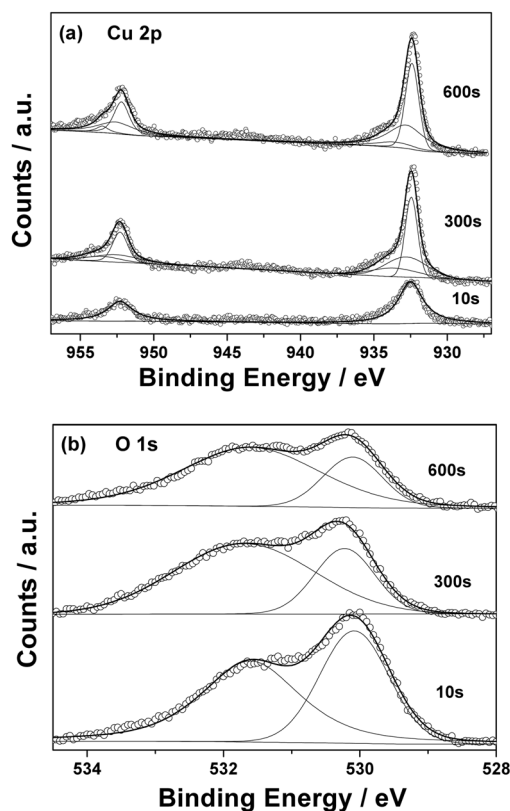


Fig. 2. XPS spectra of (a) Cu2p and (b) O1s in the electrodes. The 10, 300 and 600 s represent electrodeposition time.



Fig. 3 shows SEM images of the electrodes fabricated by pulse electrodeposition with current densities of -1 , -2 , -3 , and -4 mA/cm². In the present study, on-time and total deposition time is 0.1 s and 10 s, respectively. As shown in the Fig. 3, the electrodes formed by pulse current mode consist of more than 70% of cubes and the rest of other shapes.¹⁸⁻²⁰ However, in our study, as applied current density is increased, an average size of cubes is reduced, that is, 375, 335, 195, and 163 nm at -1 , -2 , -3 , and -4 mA/cm², respectively. Moreover, the electrode prepared by pulse electrodeposition at -1 , -2 , -3 , and -4 mA/cm² displays size deviation of ± 30.82 , 59.91, 18.82, and 12.94, respectively. Especially, the Cu₂O cube formed at the largest current density of -4 mA/cm² has the smallest size and narrowest deviation of size. Fig. 3(e) and (f) show low and high resolution TEM images of

the cube in the electrode electrodeposited at -3 mA/cm². As indicated in the Fig. 3(e), the size of the cube is about 190 nm, which is well consistent with SEM image in the electrode (Fig. 3(c)). However, the single-crystal texture for the (100) orientation of Cu₂O with d-spacing of 0.213 nm, not Cu metallic phase. Also, it is evident that the inset of the Fig. 3(e) displays transmission electron diffraction (TED) pattern indicative of (100) orientation of Cu₂O. As a result, size-controlled Cu₂O nanocubes could be synthesized by pulse electrodeposition as a function of applied current density. However, although the average size of the nanocubes is decreased, the number of the nanocubes is increased with increasing reduction current. There would be two mechanisms for the formation of the Cu₂O nanocubes, i.e. the nucleation followed by the formation of new Cu₂O grains and growth of existing nuclei. The deposition of Cu₂O takes place only when the potential of the cathode is lower than the equilibrium electrode potential of the Cu₂O/Cu²⁺; hence, a certain magnitude of cathode potential is necessary. The relationship between the overpotential and nucleation rates has been given as follows:

$$N = a \cdot \exp\left(-\frac{b}{\eta_k}\right) \quad (4)$$

In the equation (4), the N is the nucleation rate; η_k is the cathode overpotential; a and b are constants.²³ It can be seen that higher overpotential, which is higher reduction current, produces much higher nucleation rates and larger nucleation sites in the electro-crystallization process. Hence, this could lead to large number of deposited Cu₂O nanocubes with small size. As shown in Fig. 3(f), the XRD peaks at around 36.4 and 42.2 assigned to (111) and (200) plane of the Cu₂O crystal structure, respectively, were found. The relative intensity ratios of the (200) to (111) in the Cu₂O nanocubes are relatively higher than that of the reference. According to Gibbs-Wulff's theorem, for the cubic crystallographic system, both the {111} and {100} faces can be easily maintained in the final appearance due to an equilibrium shape in order to minimize its interfacial free energy.²⁴ In addition, the morphology of the deposits shows a strong dependence on the reaction conditions, such as pH of the initial solution, temperature, reaction time and applied current density. Especially, it is likely that since the relative intensity ratios of the (200) to (111) in the Cu₂O nanocubes are relatively higher than that of the reference, the Cu₂O nano-cubes show

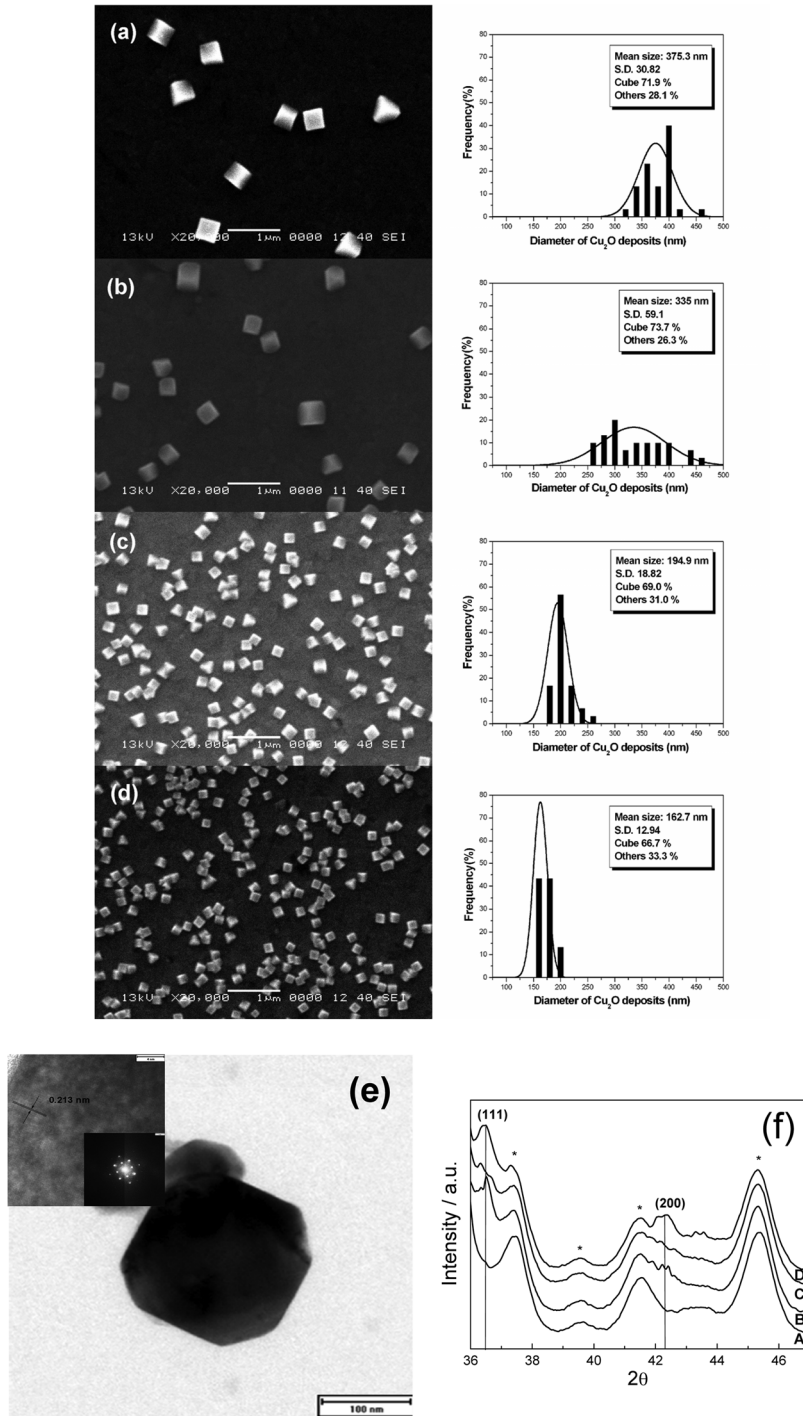


Fig. 3. SEM images and size histograms of the electrodes electrodeposited at (a) -1, (b) -2, (c) -3 and (d) -4 mA/cm². (e) Low and high magnification TEM images of Cu₂O nanocube electrodeposited at -3 mA/cm². (The inset is TED pattern.) (f) XRD patterns of the electrodes electrodeposited at -1 (A), -2 (B), -3 (C) and -4 (D) mA/cm². The (*) mark represents the XRD patterns of ITO glass.

growth along the $\langle 100 \rangle$ direction in the condition, which is well consistent with TEM images.

4. Conclusions

We found that phase transition between oxidative and metallic state of Cu_2O and Cu could be controlled as a function of an electrodeposition time under reduction current mode. Especially, the Cu_2O nanocubes without any metallic agglomerate were obtained by means of electrodeposition during a short deposition time. Thus, the highly uniform size-controlled Cu_2O nanocubes were fabricated using pulse electrodeposition method as a function of applied current density.

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